XP-002291004

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AN - 2000-140736 [13]

AP - JP19980173660 19980619

CPY - ISHI

- KINZ

DC - E36 J01 M13

DR - 1532-P

FS - CPI

IC - B01D69/12; B01D71/02; C01B3/56

MC - E11-Q01 E31-A03 J01-E03E M13-A M13-G01

M3 - [01] C101 C550 C810 M411 M720 M903 M904 M910 N104 N163 N164 Q431 Q463 Q464; R01532-K R01532-P; 1532-P

PA - (ISHI) ISHIKAWAJIMA HARIMA HEAVY IND

- (KINZ) NIPPON KINZOKU IND CO LTD

PN - JP2000005580 A 20000111 DW200013 B01D71/02 007pp

PR - JP19980173660 19980619

XA - C2000-043788

XIC - B01D-069/12; B01D-071/02; C01B-003/56

- AB JP2000005580 NOVELTY A composite hydrogen permeation film is formed by joining and composing palladium or palladium alloy film with metallic porous board in the hydrogen separation apparatus.
 - DETAILED DESCRIPTION INDEPENDENT CLAIMS are also included for the following: (i) manufacture of composite hydrogen permeation film which involves using palladium or palladium alloy film by plating, deposition or sputtering on a metal substrate and forming foil of palladium or palladium alloy. The formed foil is peeled off and the metal powder is baked and forms a porous board. A pressure of 10 or less N/mm2 is applied and is joined and composed in non-oxidizing gas atmosphere including exfoliative foil and porous board in the vacuum of 500-1000 deg. C. (ii) repairing the pinhole produced on the composite hydrogen permeation film. A solvent is added to palladium or palladium alloy of 1 mu m or less particle size and sets as a paste shape. After the paste closes the pinhole produced in palladium or palladium alloy film, then heated in non-oxidizing atmosphere containing vacuum of 400-900 deg. C.
 - USE None given.
- ADVANTAGE High rate of hydrogen permeation is maintained using the palladium or palladium alloy thin film. The composite hydrogen permeation film having pressure resistance which joins the reinforcement material so that a thin palladium film bears differential voltage. The pinhole formed is repaired. A very thin film is obtained.
- (Dwg.0/4)

CN - R01532-P

DRL - 1532-P

IW - COMPOSITE HYDROGEN PERMEATE FILM PRESSURE RESISTANCE MAINTAIN HIGH RATE HYDROGEN PERMEATE FORMING JOIN COMPOSE PALLADIUM PALLADIUM ALLOY FILM METALLIC POROUS BOARD HYDROGEN SEPARATE APPARATUS

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NC - 001

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OPD - 1998-06-19

ORD - 2000-01-11

PAW - (ISHI) ISHIKAWAJIMA HARIMA HEAVY IND

- (KINZ) NIPPON KINZOKU IND CO LTD

TI - Composite hydrogen permeation film having pressure resistance and maintains high rate of hydrogen permeation - is formed by joining and composing palladium or palladium alloy film with metallic porous board in the hydrogen separation apparatus

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